

ATTORNEY DOCKET NO.: JC-7109-CIP

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of
SHAO-CHUNG HU; TENG-CHUN
TSAI; CHIA-LIN HSU; AND YUNG-
TSUNG WEI

Group Art Unit: 2813

Examiner: N / A

Serial No.: 10/603,924

Filed: June 24, 2003

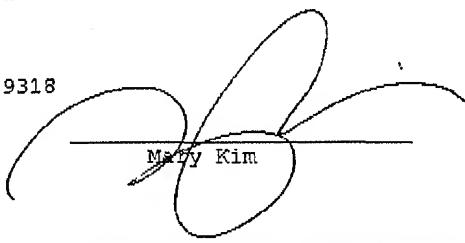
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EXAMINER : N/A
USPTO ART UNIT : 2813
FACSIMILE NO.: 703-872-9318

on October 21, 2003
Mary Kim

PRELIMINARY AMENDMENT

Dear Sir:

In connection with the above-referenced patent application,
please withdraw the Preliminary Amendment filed on June 24, 2003
and enter the following Preliminary Amendments: